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EXAMINER

JONES, H

ART UNIT

PAPER NUMBER

2763

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Please find below and/or attached an Office communication concerning this application or proceeding.

Commissioner of Patents and Trademarks

Office Action Summary

Application No.
08/889,440

Applicant(s)
Takeuchi et al.

Examiner
Hugh Jones

Group Art Unit
2763



☒ Responsive to communication(s) filed on May 22, 2000

☒ This action is **FINAL**.

☐ Since this application is in condition for allowance except for formal matters, **prosecution as to the merits is closed** in accordance with the practice under *Ex parte Quayle*, 35 C.D. 11; 453 O.G. 213.

A shortened statutory period for response to this action is set to expire 3 month(s), or thirty days, whichever is longer, from the mailing date of this communication. Failure to respond within the period for response will cause the application to become abandoned. (35 U.S.C. § 133). Extensions of time may be obtained under the provisions of 37 CFR 1.136(a).

Disposition of Claim

☒ Claim(s) 1-9 and 11-31 is/are pending in the application.

Of the above, claim(s) _____ is/are withdrawn from consideration.

☐ Claim(s) _____ is/are allowed.

☒ Claim(s) 1-9 and 11-31 is/are rejected.

☐ Claim(s) _____ is/are objected to.

☐ Claims _____ are subject to restriction or election requirement.

Application Papers

☐ See the attached Notice of Draftsperson's Patent Drawing Review, PTO-948.

☐ The drawing(s) filed on _____ is/are objected to by the Examiner.

☐ The proposed drawing correction, filed on _____ is ☐ approved ☐ disapproved.

☐ The specification is objected to by the Examiner.

☐ The oath or declaration is objected to by the Examiner.

Priority under 35 U.S.C. § 119

☒ Acknowledgement is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d).

☒ All ☐ Some* ☐ None of the CERTIFIED copies of the priority documents have been

☒ received.

☐ received in Application No. (Series Code/Serial Number) _____.

☐ received in this national stage application from the International Bureau (PCT Rule 17.2(a)).

*Certified copies not received: _____

☐ Acknowledgement is made of a claim for domestic priority under 35 U.S.C. § 119(e).

Attachment(s)

☒ Notice of References Cited, PTO-892

☐ Information Disclosure Statement(s), PTO-1449, Paper No(s). _____

☐ Interview Summary, PTO-413

☐ Notice of Draftsperson's Patent Drawing Review, PTO-948

☐ Notice of Informal Patent Application, PTO-152

— SEE OFFICE ACTION ON THE FOLLOWING PAGES —

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DETAILED ACTION

Claim Rejections - 35 USC § 101

1. **Claims 20-22 are rejected under 35 U.S.C. 101 because the claimed invention is directed to non-statutory subject matter.** The applicant is attempting to claim an algorithm, specifically a simulation algorithm directed at abstract ideas. It is also not clear what constitutes the end use of the invention, as per claims 20-22. As per remarks (pg. 6 of paper # 8) concerning tangible results; what is the useful result of simulating phenomena of a “combined particle”? These claims represent abstract ideas without any useful application.

Claim Rejections - 35 USC § 112

2. The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

3. **Claims 1-9 and 11-31 are rejected under 35 U.S.C. 112, first paragraph, as containing subject matter which was not described in the specification in such a way as to enable one skilled in the art to which it pertains, or with which it is most nearly connected, to make and/or use the invention.**

4. As per claims directed at “combined particles” (claims 1-9 and 11-31), Examiner has reviewed pp. 31-33 of the specification. The specification only describes the composition of the combined particles; but, does not describe how the components of the combined particle are

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combined. The meaning is not clear especially in light of Applicant's various comments.

Therefore, *Examiner repeats the request for a copy of Applicant's software package so that Examiner can determine what constitutes "combined"*.

5. As per claims 6, 8, and 29, wherein "...indicating whether the smaller particles of a respective individual particle are fixed against center of mass of the individual particle...", it is still not clear what the individual particles and smaller particles are. Under one assumption, the individual particle is a cluster or some similar entity of adsorbate particles and the smaller particles are individual adsorbate particles (the cohesive forces would have to be greater than the kinetic energies of the individual particles [and which I assume are significant since they are being generated" and must have enough momentum to reach the substrate])). No mention has been made concerning clusters in the specification. On the other hand, if the individual particle is on molecule or ion, then the smaller particles refer to electrons, etc. Of course in the case of electrons, they are not fixed with respect to the center of mass of the larger particle.

6. As per claim 27, wherein "...each substrate particle includes a fixed particle, a temperature control particle and a free particle...", it is not clear how a substrate particle can include a free particle since by definition a substrate particle is connected to a lattice. The meaning is still not clear especially in light of Applicant's various comments.

7. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

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8. **Claims 1-3, 5-6, 8-9, 12, 15-18, 20-23, and 29 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.**

9. A number of claims were found to be indefinite because they contained terms which were unclear in their meaning.

10. As per claims 1-3, 5-6, 8-9, 12, 15-18, and 20-23, it is not clear what the terms "combined particle" and "individual particle(s)" means with respect to the following. This is evident from examination of claims 1 and 2. In claim 1, the following is stated, "...a combined particle formed of individual particles; however, in claim 3, the following is stated, "wherein the combined particle is formed of substrate particles and adsorbate particles, each said individual particle being an adsorbate particle." Is a combined particle formed of individual particles, where by definition, the individual particles are adsorbate particles, or is the combined particle is formed of substrate particles and adsorbate particles. It is also unclear what is meant by "combined particle." The issue is still not resolved, and the rejection is reasserted.

11. As per claim 29, wherein, "...each adsorbate particle includes a plurality of smaller particles...", it is not clear from the claims what this means. Is it an adsorbate particle in the sense of the combined particle" and the smaller particles are individual adsorbate particles, or is it an individual adsorbate particle wherein the smaller particles are the electrons, ions, etc.?

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Claim Rejections - 35 USC § 103

12. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

13. As noted above and during prosecution of this case, there exist issues concerning the Applicant's definitions of terms such as individual particle, combined particle, smaller particle, etc. The examiner has examined the merits of the claims based on the the most reasonable interpretation of those terms.

14. In general, the applicants are disclosing method and apparatus to simulate physical interaction of (in the more narrow claims) adsorbates and a substrate. There is an abundance of publications concerning this topic as well as animated display of such simulations. The Applicant has emphasized the concept "*combined*" throughout the claims; if there is special significance to this term (such as a new interpretation pertaining to the underlying physical interactions between particles), it is not supported by the specification. The prior art rejections will be based on the examiner's interpretation of the specification and claims.

15. **Claims 1-9 and 11-31 are rejected under 35 U.S. C. 103 (a) as being unpatentable over Misaka et al. in view of Baumann et al., the Examiner's own experience and the taking of Official Notice.** The full rejection (which is essentially the original rejection, modified to take

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into account Applicant's amendment) is presented in full for Applicant's benefit. This is followed by new art rejections, which are presented separately, in order to avoid confusion.

16. Misaka et al. disclose a dry-etching process simulator wherein a surface reaction model is used to simulate topological evolutions by taking into account the existence of adsorbed radicals on the substrate surface. Misaka et al. apparently do not mention "combined particles". Baumann et al. disclose 3D modeling of sputtering using a mesoscopic hard-sphere Monte Carlo model. This work is included because Baumann et al. go further than Misaka et al. as pertains to "combined particles" (see fig. 1 of Baumann et al.). Baumann et al. simulate the behavior of clusters as they interact with a substrate (note that the use of ion cluster beams and molecular beams for deposition and/or sputtering are well known techniques; this phenomena has also been simulated.). Not all details of the applicant's disclosure are present in these two inventions; however, both could easily be used to obtain results concerning the physical phenomena which the applicant is interested in. Both sets of inventors are concerned with the simulating the dynamics of particles which are interacting with a substrate during processing of the substrate. Thus, it would have been obvious to one of ordinary skill in the art at the time of the invention to combine the two works. The claims are reviewed and the contributions by each inventor, as outlined above, are noted.

17. **As per claim 1, this is concerned with an apparatus for simulating phenomena of a combined particle formed of individual particles, (Misaka et al.: figs. 1, 2, 3b, 4), comprising: a kinetic condition setting unit (this is inherent in particle simulators such as monte Carlo**

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simulators) which sets information for defining a plurality of generation periods and a corresponding number of individual particles to be generated during each generation period (Misaka et al.: figs. 1, 2, 5 ("calculate fluxes"); col. 2, lines 29-34 and 49-59; Baumann et al.: pg. 4.4.1); and

a particle motion computing unit which generates the individual particles in accordance with the information set by the kinetic condition setting unit and computes motion of the generated individual particles, to simulate phenomena of the combined particle, each individual particle having a corresponding emission source (again, this is inherent in particle simulators such as Monte Carlo simulators; Misaka et al.: abstract; fig. 1,2; col. 2 lines 49-59 and 59-64; col. 3, lines 3-68; col. 4, lines 1-6; Baumann et al.: pg. 4.4.1);

for each individual particle, the kinetic condition setting unit sets a region indicating a position of the corresponding emission source (Misaka et al.: fig. 1, # 15; also inherent in figs. 2, 7, 8b, 10; Baumann et al.: inherent in fig. 1), and

the particle motion computing unit generates each individual particle in accordance with the position of the corresponding emission source (Misaka et al.: fig. 1, # 15; Baumann et al.: inherent in fig. 1).

18. As per claim 2, this is concerned with an apparatus as in claim 1, wherein the combined particle is formed of substrate particles and adsorbate particles (Misaka et al.: abstract; figs. 1, 2, 3b, 4; col. 1, lines 35-68; col. 3, lines 16-68; col. 4, lines 50-65; Baumann et al. fig. 1).

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19. As per claim 3, this is concerned with an apparatus as in claim 1, wherein the combined particle is formed of substrate particles and adsorbate particles, each said individual particle being an adsorbate particle (Misaka et al.: abstract; figs. 1, 2, 3b, 4; col. 1, lines 35-68; col. 3, lines 16-68; col. 4, lines 50-65; Baumann et al.: inherent in fig. 2), and,

before generating the individual particles, the particle motion computing unit generates the substrate particles (this would seem to be obvious; why generate particles which are to interact with a target if the target is not there; Misaka et al.: figs. 1, 2, 4, 5, 7, 8b, 9, 10; Baumann et al.:

fig. 1).

20. As per claim 4, this is concerned with an apparatus as in claim 1, further comprising:

a display which allows a user to enter the information set by the kinetic condition setting unit (this is standard with respect to particle simulators in general. I have personally done this as it pertains to Monte Carlo simulations).

21. As per claim 5, this is concerned with an apparatus as in claim 1, wherein the combined particle is formed of a first type of particle and a second type of particle, each of said individual particles being the first type of particle (Misaka et al.: abstract; figs. 1, 2, 3b, 4; col. 1, lines 35-68; col. 3, lines 16-68; col. 4, lines 50-65; Baumann et al. -. fig. 1; pg. 4.4.1), and

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the kinetic condition setting unit sets information for generating the second type of particle (obviously, this information must be provided for each species; Misaka et al.: figs. 1, 2, 5 ("calculate fluxes"),- col. 2, lines 29-34 and 49-59, Baumann et al.: pg. 4.4.1)

22. As per claim 6, this is concerned with an apparatus as in claim 1, wherein each individual particle is formed of smaller particles (Misaka et al.: fig. 1 ("radical"), fig. 2, fig. 4 (b,c,d); Baumann et al. - fig. 1; pg. 4.4.1);

the information set by the kinetic condition setting unit includes information indicating whether the smaller particles of a respective individual particle are static against center of mass of the individual particle (this limitation is not addressed due to the 112 issues raised); and

when the particle motion computing unit generates an individual particle and the information set by the kinetic condition setting unit indicates that the smaller particles of the respective individual particle are not static against the center of mass, the particle motion computing unit provides a random orientation to the smaller particles of the individual particle (Official notice is taken that this physical phenomena and approximations so as to take it into account in simulations were well known in the art at the time of the invention. [see for example studies of ion attachment to electrodes submersed in salt solutions, studies of nucleation, or the motion of electrons around moving atoms or molecules]).

23. As per claim 7, this is concerned with an apparatus as in claim 6, further comprising:

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a display which allows a user to enter the information set by the kinetic condition setting unit (this is standard with respect to particle simulators in general. I have personally done this as it pertains to Monte Carlo simulations).

24. As per claim 8, this is concerned with an apparatus as in claim 1, wherein each individual particle is formed of smaller particles (Misaka et al.: fig. 1 ("radical"), fig. 2, fig. 4 (b,c,d); Baumann et al.: fig. 1; pg. 4.4.1),

the information set by the kinetic condition setting unit includes information indicating whether the smaller particles of a respective individual particle are static against center of mass of the individual particle (this limitation is not addressed due to the 112 issues raised), **and**

when the particle motion computing unit generates an individual particle and the information set by the kinetic condition setting unit indicates that the smaller particles of the respective individual particle are not static against the center of mass, the particle motion computing unit provides an initial velocity to the smaller particles of the individual (I assume the applicant is talking about molecules here? [in which case the parts of the molecule interact with each other via vibrational modes, and thus are not bound]) **particle** (Official notice is taken that this physical phenomena and approximations so as to take it into account in simulations were well known in the art at the time of the invention. [see for example studies of ion attachment to electrodes submersed in salt solutions, studies of nucleation, or the motion of electrons around moving atoms or molecules]).

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25. As per claim 9, this is concerned with an apparatus as in claim 1, wherein, when generating an individual particle, the particle motion computing unit provides a random direction within a cone pointed at the substrate and being centered at a point of generation of center of mass velocity of the individual particle (this is inherent in particle simulations in general, and in Monte Carlo simulations, in particular [see for example studies of gaseous discharges wherein an electron is emitted from a cathode or an electron is ejected from an atom due to collisional ionization]).

26. As per claim 11, this is concerned with an apparatus as in claim 1, further comprising a display which displays the information set by the kinetic condition setting unit (this is standard with respect to particle simulators in general. I have personally done this as it pertains to Monte Carlo simulations).

27. As per claim 12, this is concerned with an apparatus for simulating phenomena of a combined particle formed of individual particles, each individual particle having a corresponding emission source, the apparatus comprising:

an input device which allows a user to designate a region (this is standard with respect to particle simulators in general. I have seen done this as it pertains to Monte Carlo simulation [specifying the position of the cathode which is to eject electrons]; Misaka et al.: figs, 1, 5, 7, 8b, 9, 10- Baumann et al.: inherent in fig. 1);

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a kinetic condition setting unit which, for each individual particle, sets the region designed by the user as a region indicating a position of the corresponding emission source (Misaka et al. fig. 1, # 15; Baumann et al.: inherent in fig. 1); and

a particle motion computing unit which generates the individual particles in accordance with the position of the corresponding emission source as indicated by the region designated by the user and computes motion of the generated individual particles, to simulate phenomena of the combined particle (Misaka et al.: fig. 1, # 15; fig. 5 - Baumann et al.: pg. 4.4.1).

28. As per claim 13, this is concerned with an apparatus as in claim 12, wherein the input device is a display (this is standard with respect to particle simulators in general. I have personally done this as it pertains to Monte Carlo simulations).

29. As per claim 14, this is concerned with an apparatus as in claim 12, further comprising a display which displays the information set by the kinetic condition setting unit (this is standard with respect to particle simulators in general. I have personally done this as it pertains to Monte Carlo simulations).

30. As per claim 15, this is concerned with an apparatus as in claim 14, wherein the display shows the individual particles generated by the particle motion computing unit and indicates the motion computed by the particle motion computing unit (this is standard in the art; I have seen this type of display at conferences [Official notice is taken that this feature was well known in the art at the time of the invention.]).

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31. As per claim 16, this is concerned with an apparatus for simulating phenomena of a combined particle formed of individual particles, comprising:

a kinetic condition setting unit (this is inherent in particle simulators such as monte Carlo simulators) which sets information for defining kinetic conditions of the individual particles (Misaka et al.: figs. 1, 2, 5 ("calculate fluxes"); col. 2, lines 29-34 and 49-59; Baumann et al.: pg. 4.4.1); and

a particle motion computing unit which generates the individual particles in accordance with the information set by the kinetic condition setting unit and the position of the corresponding emission source and computes motion of the generated individual particles, to simulate phenomena of the combined particle, each individual particle having a corresponding emission source (again, this is inherent in particle simulators such as Monte Carlo simulators; Misaka et al.: abstract; fig. 1, 2 col. 2 lines 49-59 and 59-64; col. 3, lines 3-68; col. 4, lines 1-6; Baumann et al.: pg. 4.4.1).

32. As per claim 17, this is concerned with an apparatus as in claim 16, wherein

the combined particle is formed a first type of particle and a second type of particle, the first type of particle moving towards the second type of particle, each of said individual particles being the first type of particle (Misaka et al. - fig. 1, 2, 3b; Baumann et al.: fig. 1),

the kinetic condition setting unit sets a region for defining an initial position of the individual particles (Misaka et al.: figs. 1, 5; Baumann et al.: inherent on pg. 4.4.1),

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the apparatus further comprises a display which displays the relationship between the region set by the kinetic condition setting unit and a region indicating a position of a second type of particle forming the combined particle (this is standard in the art; I have seen this type of display at conferences [Official notice is taken that this feature was well known in the art at the time of the invention.]).

33. As per claim 18, this is concerned with an apparatus as in claim 17, wherein the kinetic condition setting unit sets information for providing a direction of velocity to the individual particles (Misaka et al.: fig. 1 # 15; Baumann et al.: inherent on pg. 4.4.1), and

the display shows the direction of velocity with respect to the region set by the kinetic condition setting unit and the region indicating the position of the second type of particle (this is standard in the art; I have seen this type of display at conferences [Official notice is taken that this feature was well known in the art at the time of the invention.]).

34. As per claim 19, this is concerned with an apparatus as in claim 16, further comprising a display which displays the information set by the kinetic condition setting unit (this is standard with respect to particle simulators in general. I have personally done this as it pertains to Monte Carlo simulations).

35. As per claim 20, this is concerned with a computer-implemented method for simulating phenomena of a combined particle formed of individual particles, comprising the steps of:

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setting information for defining a plurality of generation periods and a corresponding number of individual particles to be generated during each generation period (Misaka et al.: fig. 1, # 15; Baumann et al.: inherent on pg. 4.4.1);

generating the individual particles in accordance with the information set in the setting step and the position of the corresponding emission source (Misaka et al.: fig. 1, # 15; Baumann et al.: inherent on pg. 4.4.1); and

computing motion of the generated individual particles, to simulate phenomena of the combined particle (again, this is inherent in particle simulators such as Monte Carlo simulators, Misaka et al.: abstract; fig. 1, 2; col. 2 lines 49-59 and 59-64; col. 3, lines 3-68; col. 4, lines 1-6; Baumann et al.: pg. 4.4.1).

36. As per claim 21, this is concerned with a method as in claim 20, wherein the combined particle is formed of substrate particles and adsorbate particles, each said individual particle being an adsorbate particle (Misaka et al.: abstract; figs. 1, 2, 3b, 4; col. 1, lines 35-68; col. 3, lines 16-68; col. 4, lines 50-65; Baumann et al.: fig. 1, inherent in fig. 2).

37. As per claim 22, this is concerned with a computer-implemented method for simulating phenomena of a combined particle formed of individual particles, each individual particle having a corresponding emission source, the method comprising the steps of

setting, for each individual particle, a region indicating a position of the corresponding emission source (this is standard with respect to particle simulators in general. I

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have seen done this as it pertains to Monte Carlo simulation [specifying the position of the cathode which is to eject electrons]; Misaka et al.: figs. 1, 5, 7, 8b, 9, 10; Baumann et al.: inherent on pg. 4.4.1),

generating the individual particles in accordance with the position of the corresponding emission source as indicated by the region set in the setting step (Misaka et al.: fig. 1, # 15; Baumann et al.: inherent on pg. 4.4.1);

computing motion of the generated individual particles, to simulate phenomena of the combined particle (Misaka et al.: fig. 1, # 15; Baumann et al.: pg. 4.4. 1).

38. As per claim 23, this is concerned with an apparatus for simulating phenomena of a combined particle formed of individual particles, comprising:

setting information for defining kinetic conditions of the individual particles;

displaying the set information (Misaka et al.: figs. 1, 2, 5 ("calculate fluxes"); col. 2, lines 29-34 and 49-59; Baumann et al.: inherent on pg. 4.4.1);

generating the individual particles in accordance with the set information and the positions of the corresponding emission sources (again, this is inherent in particle simulators such as Monte Carlo simulators; Misaka et al.: abstract; fig. 1,2; col. 2 lines 49-59 and 59-64; col. 3, lines 3-68; col. 4, lines 1-6; Baumann et al.: inherent on pg. 4.4.1); and

computing motion of the generated individual particles, to simulate phenomena of the combined particle, each individual particle having a corresponding emission source

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(again, this is inherent in particle simulators such as Monte Carlo simulators; Misaka et al.: abstract; fig. 1, 2; col. 2 lines 49-59 and 59-64; col. 3, lines 3-68; col. 4, lines 1-6; Baumann et al.: pg. 4.4.1).

39. As per claim 24, this is concerned with an apparatus for simulating phenomena of a combined particle formed of substrate particles and adsorbate particles, comprising:

a kinetic condition setting unit (this is inherent in particle simulators such as monte Carlo simulators) **which sets information for defining kinetic conditions of the adsorbate particles** (Misaka et al.: figs. 1, 2, 5 ("calculate fluxes"); col. 2, lines 29-34 and 49-59; Baumann et al.: inherent on pg. 4.4.1), and

a particle motion computing unit which generates the adsorbate particles in accordance with the information set by the kinetic condition setting unit and computes motion of the generated adsorbate particles, to simulate phenomena of the combined particle, each adsorbate particle having a corresponding emission source (again, this is inherent in particle simulators such as Monte Carlo simulators; Misaka et al.: abstract; fig. 1,2; col. 2 lines 49-59 and 59-64; col. 3, lines 3-68; col. 4, lines 1-6; Baumann et al.: pg. 4.4.1);

for each adsorbate particle, the kinetic condition setting unit sets a region indicating a position of the corresponding emission source (Misaka et al.: fig. 1, # 15; also inherent in figs. 2, 7, 8b, 10; Baumann et al.: inherent on pg. 4.4.1), and

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the particle motion computing unit generates each adsorbate particle in accordance with the position of the corresponding emission source as indicated by the region set by the kinetic condition setting unit (Misaka et al.: fig. 1, # 15; Baumann et al.: pg. 4.4.1).

40. As per claim 25, this is concerned with an apparatus as in claim 24, wherein the information set by the kinetic condition setting unit (this is inherent in particle simulators such as Monte Carlo simulators) defines a plurality of generation periods and a corresponding number of adsorbate particles to be generated during each generation period by the particle motion computing unit (Misaka et al.: figs. 1, 2, 5 ("calculate fluxes"); col. 2, lines 29-34 and 49-59; Baumann et al.: inherent on pg. 4.4.1).

41. As per claim 26, this is concerned with an apparatus as in claim 24, wherein the information set by the kinetic condition setting unit includes information for defining kinetic conditions of the substrate particles (Misaka et al.: figs. 1, 2, 5 ("calculate fluxes"); col. 2, lines 29-34 and 49-59; Baumann et al.: inherent on pg. 4.4.1); and

the particle motion computing unit generates the substrate particles before generating the adsorbate particles (this would seem to be obvious; why generate particles which are to interact with a target if the target is not there; Misaka et al.: figs. 1, 2, 4, 5, 7, 8b, 9, 10; Baumann et al.: pg. 4.4.1).

42. As per claim 27, this is concerned with an apparatus as in claim 24, wherein

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each substrate particle includes a fixed particle, a temperature control particle and a free particle (this limitation is not addressed due to the 112 issues raised; [however, Baumann et al. does address the issue of temperature: fig. 6]),

the information set by the kinetic condition setting unit includes information for defining kinetic conditions of the fixed particle, the temperature control particle and the free particle of each substrate particle (Misaka et al.: figs. 1, 2, 5 ("calculate fluxes"); col. 2, lines 29-34 and 49-59; Baumann et al.: inherent on pg. 4.4.1), and

the particle motion computing unit generates the fixed particle, the temperature control particle and the free particle of each substrate particle in accordance with the information set by the kinetic condition setting unit (again, this is inherent in particle simulators such as Monte Carlo simulators; Misaka et al.: abstract; fig. 1,2; col. 2 lines 49-59 and 59-64; col. 3, lines 3-68; col. 4, lines 1-6; Baumann et al.: inherent on pg. 4.4.1).

43. **As per claim 28, this is concerned with an apparatus as in claim 24, further comprising a display which displays the information set by the kinetic condition setting unit** (this is standard with respect to particle simulators in general. I have personally done this as it pertains to Monte Carlo simulations).

44. **As per claim 29, this is concerned with an apparatus as in claim 24, wherein each adsorbate particle includes a plurality of smaller particles** (Misaka et al.: fig. 1 ("radical"), fig. 2, fig. 4 (b,c,d); Baumann et al. fig. 1);

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the information set by the kinetic condition setting unit includes information indicating whether the smaller particles of a respective adsorbate particle are static against center of mass of the adsorbate particle (this limitation is not addressed due to the 112 issues raised); and

when the particle motion computing unit generates an adsorbate article and the information set by the kinetic condition setting unit indicates that the smaller particles of the respective adsorbate particle are not static against center of mass, the particle motion computing unit provides a random orientation to the smaller particles of the adsorbate particle (Official notice is taken that this physical phenomena and approximations so as to take it into account in simulations were well known in the art at the time of the invention. [see for example studies of ion attachment to electrodes submersed in salt solutions, studies of nucleation, or the motion of electrons around moving atoms or molecules]).

45. As per claim 30, this is concerned with an apparatus as in claim 29, wherein, when the particle motion computing unit generates an adsorbate particle and the information set by the kinetic condition setting unit indicates that the smaller particles of the respective adsorbate particle are not fixed against center of mass, the particle motion computing unit provides an initial velocity to the smaller particles of the adsorbate particle (Official notice is taken that this physical phenomena and approximations so as to take it into account in simulations were well known in the art at the time of the invention. [see for example studies of ion attachment

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to electrodes submersed in salt solutions, studies of nucleation, or the motion of electrons around moving atoms or molecules]).

46. As per claim 31, this is concerned with an apparatus as in claim 24, wherein, when generating an adsorbate particle, the particle motion computing unit provides a random direction of center of mass velocity of the adsorbate particle (Official notice is taken that this physical phenomena and approximations so as to take it into account in simulations were well known in the art at the time of the invention. [see for example studies of ion attachment to electrodes submersed in salt solutions, studies of nucleation, or the motion of electrons around moving atoms or molecules])).

Art Rejections (asserted in paper # 15)

Claim Rejections - 35 USC § 102

47. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless --

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

48. Claims 1, 12, 16, 20 and 22-24 are rejected under 35 U.S.C. 102(b) as being anticipated by Reeves (1983) or Cohen (1992).

49. Reeves discloses animation of particle behavior and discloses the concept of combined particle. On page 91,

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"First, an object is represented not by a set of primitive surface elements, such as polygons or patches, that define its boundary, but as clouds of primitive particles that define its volume."

Section 2.1 discloses particle generation. Section 2.2 discloses:

"For each new particle generated, the particle system must determine values for the following attributes:

- (1) initial position,*
- (2) initial velocity (both speed and direction),*
- (3) initial size,*
- (4) initial color,*
- (5) initial transparency,*
- (6) shape,*
- (7) lifetime.*

Section 2.3 discloses particle dynamics.

50. Cohen discloses *"Computer animations, quantum mechanics and elementary particles."*

See entire disclosure. The following is from pg. 165;

"In a typical animation, starting from a small number of virtual particles, the number tends to increase as a function of time, signaling the deviation from the physical states. A physical particle contains a cloud of finite size of virtual particles. The animation actually allows us to see the formation of such clouds. It is rather amusing to identify dressed objects manifesting collective behavior, and then analyze the space renormalization group of the clouds by zooming in."

On page 166, the following is found:

The visualization "dictionary" developed for computer animations of quantum systems can be applied to any process following the rules of one or several of Nature's fundamental interactions. Animation of various atomic

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and subatomic phenomena such as electron orbitals, particle collisions, radioactive decay, fusion, fission, etc. are therefore feasible and instructive."

51. Claims 1, 12, 16, 20 and 22-24 are rejected under 35 U.S.C. 102(e) as being anticipated by Kinema/SIM.

52. Kinema/SIM is a software tool that presents a simulation space for particle behavior where you can construct and animate complex physical phenomena. See entire disclosure. A number of features are subsequently listed for Applicant's benefit.

- Examples of the graphical interface are shown on pp. 1-8 to 1-9;
- the "particle window" is shown on pg. 2-7; here the particle parameters can be altered;
- "Lifetime" defines the particle lifetime (pg. 2-9);
- "particle geometry" is discussed on pg. 2-11;
- "coordinate systems" are discussed on pg. 3-3;
- entering particle parameter values via slider buttons (pg. 3-10);
- probability functions for particle speed, lifetime, emission angles (pg. 3-11);
- other relevant temporal parameters (pg. 3-16);
- GUI simulation controls (pg. 5-2);
- statistical features (ie., group behavior - pg. 5-3);
- particles, obstacles (pg. 5-5);
- details about simulation parameter values including source rate, display, particle interactions and emission sources (chapter 6);

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- range of interactions between particles (pg. 6-3);
- source rate (pg. 6-4);
- a combined particle (pg. 6-5), wherein

"The Euler mode, on the other hand, calculates forces more globally and therefore has the advantage of maintaining simulation speed. It calculates only one force per cell at time t, which is applied to all particles in the cell. ...";

- Chapter 7 discloses "Particles";
- particle coupling (pg. 7-1);
- particle examples (pg. 7-1), wherein

"Particles are the key element in Kinema/SIM simulations. They are point objects that can represent a broad range of physical and image characteristics such as mass, charge, color, motion and geometry. In your simulation, particles can represent a diversity of real or image objects such as quantum physics particles, gas molecules, aerosol droplets, bacteria, fluid flow, dust, rain, snow, sand, or pixels of images. The possibilities are as numerous as the phenomena of reality and creative animation ...

... Particles are emitted into the simulation via sources which can be visible or invisible points or geometric objects positioned in simulation space. ...";

- particles parameter window (pg. 7-3 to 7-4);
- "Sigma", a parameter related to particle-particle interactions (pp. 7-13 to 7-14);
- decay particles (pg. 7-21);
- particle coupling (pp. 7-22 to 7-23);
- Chapter 8 (source parameters);

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- sources (pg. 8-1), wherein

"Sources are origins that emit particles into the simulation, and all particles must enter the simulation via a source. Sources can be points or have spatial geometry which you can choose to see or hide in simulation space. You can define as many sources as you like for a system, but each source is restricted to emit only one particle type. (If you want to have more than one particle type originate from the same position, you can superimpose sources at the point. ...

... In the source window you assign a particle type to the source and then define the rate and speed of the particles along with their spread angle into the simulation. ..."

The "spread angle" is Applicant's "cone".;

- source window (pg. 8-3);
- source rate (pg. 8-4);
- **Spread** (pg. 8-5);
- speed (pg. 8-6);
- source position (pg. 8-10);
- display (pg. 8-11);
- geometry (pg. 8-13);
- particle emission and geometry (pp. 8-15 to 8-16);
- particle generation (pp. 8-16 to 8-17);
- Chapter 9 "Obstacles";
- Chapter 13, "electric fields";
- Chapter 15, "particle events";

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- elastic and inelastic particle collisions (pp. 15-1 to 15-2);

Claim Rejections - 35 USC § 103

53. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

54. **Claims 2-9, 11, 13-15, 17-19, 21, 25-26 and 28-31 are rejected under 35 U.S.C. 103(a) as being unpatentable over [Ohira (Applicant - Applicant's IDS) or Yamada et al.] in view of (Kinema/SIM or Reeves or Cohen), and the taking of Official Notice.**

55. Ohira et al. discloses details of a Molecular-dynamics simulation of sputtering. See: abstract; pg. 2 (Theoretical Methods) and especially fig. 1.

56. Yamada et al. discloses details of a Monte Carlo simulation of sputtering. See entire disclosure. Especially note fig. 1-3.

57. [Ohira et al. or Yamada et al.] disclose all claim limitations except for teaching animation of the simulation. Official notice is taken that it was obvious and well known to one of ordinary skill in the art at the time of the invention to animate simulations of physical processes.

[Kinema/SIM or Reeves or Cohen] provide details about animations of particles.

58. The discloses of Reeves, Kinema/SIM and Cohen were presented earlier.

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59. Claim 27 is rejected under 35 U.S.C. 103(a) as being unpatentable over [Ohira et al. (Applicant - Applicant's IDS).] in view of (Kinema/SIM or Reeves or Cohen), and the taking of Official Notice.

60. [Ohira et al.] discloses all claim limitations (see fig. 1 - temperature control particles) except for a teaching animation of the simulation. Official notice is taken that it was obvious and well known to one of ordinary skill in the art at the time of the invention to animate simulations of physical processes. [Kinema/SIM or Reeves or Cohen] provide details about animations of particles.

Response to Arguments

61. Applicant's arguments filed 5/22/2000 have been fully considered but they are not persuasive.

Regarding the 101 rejections (page 11, paper 16):

62. Examiner respectfully submits that there is no specific asserted utility and offers the following:

Patent Act, Section 101:

The Examiner reminds Applicant that disclosing a practical application for an invention is a long-established requirement.

We think it is now settled that an invention cannot be considered as having been reduced to practice in the sense that a patent can be granted for it unless a practical utility for the invention has been discovered where such utility would not be obvious. See 35 U.S.C. 101; Brenner v. Manson, 383 U.S. 519, 148 USPQ 689 (1966); In re

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Kirk, 54 CCPA 1119, 376 F.2d 936, 153 USPQ 48 (1967); In re Joly, 54 CCPA 1159, 376 F.2d 906, 153 USPQ 45 (1967).

See *In re Kawai*, 178 U.S.P.Q 158, 163 (BNA) (C.C.P.A. 1973) (Senior J. Almond writing for the unanimous court, *en banc*).

Patent Act, Section 112:

The Examiner notes Applicant's statement in the amendment, in which Applicant states (page 11):

"simulating phenomena of a combined particle"

Applicants are reminded that ***the claimed invention must be limited to a practical application.***

Mere allegations that the claimed invention ***could be useful*** for some purpose, without support in the written description showing "the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same" does not meet the requirements defined in the Patent Act, section 112, first paragraph.

63. As described in sections 2163-2164 of the Manual of Patent Examining Procedure, an applicant must show ***how to make the claimed invention*** (MPEP 2164.01(b)), and ***how to use the claimed invention*** (MPEP 2164.01(c)). An applicant is not required to provide a working example (MPEP 2164.02). However, when an applicant does not provide an example showing ***actual reduction to practice***, the applicant ***must demonstrate constructive reduction to practice*** to demonstrate possession of the invention. See *In re Brandstadter*, 179 USPQ 286 (BNA)

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(C.C.P.A. 1973), wherein Judge Rich, writing for the *unanimous in banc* court, upheld a decision by the Board of Appeals, affirming a rejection by a patent examiner under section 112, first paragraph, for failure to teach how to properly make and use the claimed invention.

64. The Examiner interprets, with respect to the practical application asserted by the Applicant, that the Applicant has not disclosed how to use the claimed invention for a practical purpose within the written description. ***The written description must teach a practical application for the claimed invention to establish constructive reduction to practice.***

It is well understood that the act of filing a United States patent application can be regarded as being a constructive reduction to practice of an invention described therein as of the filing date. It follows naturally from this that ***the written specification in the application is the evidence proving the invention of that which is reduced to practice***, i.e., the subject matter to which properly supported claims can be drawn.

We think it is now settled that an invention cannot be considered as having been reduced to practice in the sense that a patent can be granted for it unless a practical utility for the invention has been discovered where such utility would not be obvious. See 35 U.S.C. 101; Brenner v. Manson, 383 U.S. 519, 148 USPQ 689 (1966); In re Kirk, 54 CCPA 1119, 376 F.2d 936, 153 USPQ 48 (1967); In re Joly, 54 CCPA 1159, 376 F.2d 906, 153 USPQ 45 (1967). Therefore, a constructive reduction to practice, as opposed to an actual reduction to practice, is not proven unless the specification relied upon discloses a practical utility for the invention where one would not be obvious. We also think that proof of a constructive reduction to practice would also require that there be sufficient disclosure in the specification to enable any person skilled in the art to take advantage of that utility where it would not be obvious how this is done. This latter requirement is, of course, the so-called "how to use" requirement of section 112.

See *Kawai* at 163. The Examiner further notes the requirements expressed in MPEP 2164.05 :

Once the examiner has weighed all the evidence and established a reasonable basis to question the enablement provided for the claimed invention, ***the burden falls on applicant to present persuasive arguments, supported by suitable proofs where necessary***, that one skilled in the art would be able to make and use the claimed invention using the

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application as a guide. In re Brandstadter , 484 F.2d 1395,1406 - 07, 179 USPQ 286, 294 (CCPA 1973). The evidence provided by applicant need not be conclusive but merely convincing to one skilled in the art.

Regarding the 112(1) rejections (pages 12-13, paper 16):

65. As per claims directed at “combined particles” (first two full paragraphs, page 12), Examiner has reviewed pp. 31-33 of the specification. The specification only describes the possible composition of the combined particles; but, does not describe how the components of the combined particle are combined. The meaning is not clear especially in light of Applicant’s various comments in paper # 9 as well as those provided in paper # 16. Therefore, **Examiner repeats the request for a copy of Applicant’s software package so that Examiner can determine what constitutes “combined”**. Representative is reminded that the claims were rejected under 35 U.S.C. 112, first paragraph, because *they contain subject matter which was not described in the specification in such a way as to enable one skilled in the art to which it pertains, or with which it is most nearly connected, to make and/or use the invention*. In response, Representative simply asserts that it does not matter how the particles are combined. How could *one skilled in the art to which it pertains, or with which it is most nearly connected, to make and/or use the invention*, namely combined particles, if the *subject matter was not adequately described in the specification*? Furthermore, it is noted that Representative abandoned the application after notice of allowance, since Representative disagreed with Examiner’s interpretation regarding “interacting” (which of course defines how the particles are combined). Since this point is so

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important (page 13, paper # 12), the Examiner requires an explanation of the relationship between particles that make up this "combined particle".

66. As per comments (third full paragraph, page 12) regarding *individual and smaller particles*, Examiner respectfully disagrees with Representative's position and maintains the rejections. In response to the argument that the references fail to show certain features of applicant's invention, it is noted that the features upon which applicant relies (i.e., "*might be adsorbate particles*", etc.) are not recited in the rejected claim(s). Although the claims are interpreted in light of the specification, limitations from the specification are not read into the claims. See *In re Van Geuns*, 988 F.2d 1181, 26 USPQ2d 1057 (Fed. Cir. 1993).

67. As per comments (last full paragraph, page 12) regarding "*substrate particles*", a number of points need to be noted. First, Examiner responded to this issue in paragraph 9 of paper # 9.

There was no response, by Representative, to Examiner's reply; which is again recited for Applicant's benefit:

"As per comments (pg. 8 of applicant's response) regarding paragraph 10 of examiner's action, the examiner questioned how a substrate particle can include a free particle since by definition a substrate particle is tied to the lattice. In response, applicant stated (pg. 8), "As explained above, a substrate particle can form both a crystal structure and an amorphous structure..." Examiner would respectfully suggest that a collection of substrate particles can form said lattices. Furthermore, applicant states, "...Their equilibrium positions are decided by the equilibrium structure, and they vibrate around the position via their kinetic energies and interactions with surrounding particles." The examiner agrees with that characterization. Applicant then concludes, "Thus, the substrate particle is not tied to the lattice..." The examiner respectfully, but strongly, disagrees with said conclusion. By applicant's own admission (ie., the preceeding), the substrate particles are in equilibrium positions - they are dynamically tied to the lattice (regular or amorphous) via intermolecular forces - in other words, they are not free particles, as per the commonly accepted meaning of a free particle. Applicant has the option to define terms - so long as the record is clear as to the intended meaning of said word."

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In any case, in response to Representative's request for some indication where such a definition can be found, the following is submitted. First, it respectfully requested that Representative review any *elementary textbook on semiconductor physics*, especially chapters wherein crystal dynamics and atoms (*particles*) are discussed. **This is extremely well known.** Also, please review the following U. S. Patents:

68. Imai et al. disclose (col. 4, lines 24-54):

"With the substrate according to the present invention, at least one of the orientations of the periodic arrangement of the atoms on the surface of the substrate, and at least one of the orientations of the crystal axes of the lattice face of the first layer nitride semiconductor in direct contact with the substrate coincide, and the mismatch of an integer multiple (from 1 to 10) of the atomic spacing of the latter orientation and the atomic spacing of the former orientation is preferably within 5%.

The atoms periodically arranged on the surface of the substrate are those atoms which occupy the lattice points of the substrate crystal, and are positioned uppermost on the crystal surface. The integer multiple of the atomic spacing in at least one direction of the *lattice face* of the nitride of the oriented polycrystalline nitride semiconductor of the first layer is from 1 to 10. If this exceeds 10 the stacking of the atoms exposed on the substrate surface, with the atomic orbits of the nitride semiconductor becomes small so that the crystal orienting function is decreased, making it difficult to obtain a well orientated polycrystalline nitride semiconductor layer. The difference between the integer multiple of the atomic spacing in at least one direction on the lattice face of the nitride of the oriented polycrystalline nitride semiconductor, and the atomic spacing of the periodic arrangement of the atoms on the surface of the substrate in the same direction is preferably within 5%. If the difference (or mismatch) is greater than this, it becomes difficult to obtain a well oriented nitride semiconductor layer. A mismatch value of less than 3% is more preferable, and less than 1% is even more preferable."

69. Kizuki et al. discloses (col. 9, lines 4-19):

"A description is given of the principle of this third embodiment. As shown in FIGS. 5(a)-5(b), in a case where the lattice constant of the semiconductor substrate 21 is $\sqrt{2}$ times as large as the lattice constant of the epitaxially grown layer 22, when the crystal lattice arrangement of the epitaxially grown layer 22 is made in a direction rotated by 45.degree. in the surface parallel to the front surface of the semiconductor substrate 21 with respect to the crystal lattice arrangement of the

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semiconductor substrate 21, the atoms in the lattices of the epitaxially grown layer 22 are lattice-matched with every other atom in the lattice of the semiconductor substrate 21. Then the non-lattice-matched grown layer atoms 22a have dangling bonds, and the dangling bonds cause point defects in the epitaxial grown layer 22, but no dislocations are produced therein. Therefore, by providing such structure, an epitaxially grown layer with high-quality is fabricated."

70. Bruel discloses (abstract and col. 2, lines 15-25):

"The present invention relates to a process for fast doping of semiconductors, consisting in implanting foreign particles in a substrate and in rendering them electrically active so as to modify the physical properties of said substrate, wherein the foreign particles constituting the dopant material arrive on the substrate closely in time and space so that the energy brought by each particle when it is implanted in the substrate cooperates with the energy of the other particles so as to produce a local liquefaction of the substrate, allowing the particles to be positioned in the substitutional sites of the crystal lattice of the substrate and allowing said crystal lattice, which was disturbed when the particles penetrated in the substrate, to be rearranged."

"According to the invention, this process of doping is characterised in that the foreign particles or impurities constituting the dopant material arrive on the substrate closely in time and space so that the energy brought by each particle when it is implanted in the substrate, cooperates with the energy of the other particles so as to produce a local liquefaction of the substrate, allowing the particles to be positioned in the substitutional sites of the crystal lattice of the substrate and allowing said crystal lattice, which was disturbed when the particles penetrated in the substrate, to be rearranged."

The Examiner is at odds to attempt to explain to Representative that a semiconductor substrate is, by definition, a lattice (whether it is amorphous or ordered is *irrelevant*). A lattice is composed of particles (usually atoms, but could be ions - as in the case of a NaCl crystal [salt]). Therefore, such atoms are, inherently, substrate particles, and, as such, are "tied" to the lattice. The Examiner challenges Representative to provide evidence to the contrary - in the absence of such evidence, Representative's assertions are merely conclusory. In any case, while applicant may be his or her own

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lexicographer, a term in a claim may not be given a meaning repugnant to the usual meaning of that term. See *In re Hill*, 161 F.2d 367, 73 USPQ 482 (CCPA 1947).

Regarding the 112(2) rejections (pages 13-14, paper 16):

71. As per comments (pages 13-14) regarding *combined particles*, Examiner respectfully disagrees with Representative's position and maintains the rejections. The claims are confusing to the Examiner, who has formal training in this art. In response to the argument that the references fail to show certain features of applicant's invention, it is noted that the features upon which applicant relies (i.e., "... such as, for example, atoms", [first paragraph, page 14] etc.; and references to fig. 14) are not recited in the rejected claim(s). Although the claims are interpreted in light of the specification, limitations from the specification are not read into the claims. See *In re Van Geuns*, 988 F.2d 1181, 26 USPQ2d 1057 (Fed. Cir. 1993).

Regarding the 103 rejections (page 14, paper 16):

72. Representative's characterization of the teachings of Baumann and Misaka trivializes and misstates their inventions - Please refer to the detailed rejections as well as the teachings. For example, the characterization of the Baumann teaching as "...*incoming spheres* ..." ignores the teaching of a simulation of Sputtering which is what Applicant is attempting to claim. Page 4.4.2 of Baumann discloses molecular dynamic simulation (simulation of trajectories) - as mentioned in the detailed art rejection, this means that it is *inherent* that a source must exist for each particle.

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As per Misaka, see fig. 2; col. 9, line 65 to col. 10, line 9, wherein trajectories are discussed.

Representative has not provided a persuasive response to the art rejections, repeated above.

Regarding the 102(B) rejections (page 15, paper 16):

73. Representative's characterization of the teaching of Reeves trivializes and misstates the invention - Please refer to the detailed rejections as well as the teachings. For example, reference to "fuzzy" is irrelevant and has absolutely nothing to do with the issues at hand. As recited in the last Official Office Action: "Reeves discloses animation of particle behavior and discloses the concept of combined particle. On page 91,

"First, an object is represented not by a set of primitive surface elements, such as polygons or patches, that define its boundary, but as clouds of primitive particles that define its volume."

Section 2.1 discloses particle generation. Section 2.2 discloses:

"For each new particle generated, the particle system must determine values for the following attributes:

(1) initial position,

(2) initial velocity (both speed and direction),

(3) initial size,

(4) initial color,

(5) initial transparency,

(6) shape,

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(7) lifetime.

Section 2.3 discloses particle dynamics.”

Please note the bold-faced portions - **which define particle sources**.

74. As recited in the last Official Office Action, “Cohen discloses “*Computer animations, quantum mechanics and elementary particles*.” See entire disclosure. The following is from pg. 165;

“In a typical animation, starting from a small number of virtual particles, the number tends to increase as a function of time, signaling the deviation from the physical states. A physical particle contains a cloud of finite size of virtual particles. The animation actually allows us to see the formation of such clouds. It is rather amusing to identify dressed objects manifesting collective behavior, and then analyze the space renormalization group of the clouds by zooming in.”

On page 166, the following is found:

The visualization “dictionary” developed for computer animations of quantum systems can be applied to any process following the rules of one or several of Nature’s fundamental interactions. Animation of various atomic and subatomic phenomena such as electron orbitals, particle collisions, radioactive decay, fusion, fission, etc. are therefore feasible and instructive.”

Cohen discloses particle sources.

Regarding the 102(E) rejections (page 15, paper 16):

75. As recited in the last Official Office Action: “Kinema/SIM is a software tool that presents a simulation space for particle behavior where you can construct and animate complex physical

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phenomena. See entire disclosure. A number of features are subsequently listed for Applicant's benefit.

- Examples of the graphical interface are shown on pp. 1-8 to 1-9;
- the "particle window" is shown on pg. 2-7; here the particle parameters can be altered;
- "Lifetime" defines the particle lifetime (pg. 2-9);
- "particle geometry" is discussed on pg. 2-11;
- "coordinate systems" are discussed on pg. 3-3;
- entering particle parameter values via slider buttons (pg. 3-10);
- probability functions for particle speed, lifetime, emission angles (pg. 3-11);
- other relevant temporal parameters (pg. 3-16);
- GUI simulation controls (pg. 5-2);
- statistical features (ie., group behavior - pg. 5-3);
- particles, obstacles (pg. 5-5);
- details about simulation parameter values including source rate, display, particle interactions and emission sources (chapter 6);
- range of interactions between particles (pg. 6-3);
- source rate (pg. 6-4);
- a combined particle (pg. 6-5), wherein

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"The Euler mode, on the other hand, calculates forces more globally and therefore has the advantage of maintaining simulation speed. It calculates only one force per cell at time t, which is applied to all particles in the cell. ...";

- Chapter 7 discloses "**Particles**";
- **particle coupling** (pg. 7-1);
- particle examples (pg. 7-1), wherein

"Particles are the key element in Kinema/SIM simulations. They are point objects that can represent a broad range of physical and image characteristics such as mass, charge, color, motion and geometry. In your simulation, particles can represent a diversity of real or image objects such as quantum physics particles, gas molecules, aerosol droplets, bacteria, fluid flow, dust, rain, snow, sand, or pixels of images. The possibilities are as numerous as the phenomena of reality and creative animation ...

... Particles are emitted into the simulation via sources which can be visible or invisible points or geometric objects positioned in simulation space. ...";

- particles parameter window (pg. 7-3 to 7-4);
- "**Sigma**", **a parameter related to particle-particle interactions** (pp. 7-13 to 7-14);
- decay particles (pg. 7-21);
- particle coupling (pp. 7-22 to 7-23);
- Chapter 8 (source parameters);
- **sources** (pg. 8-1), wherein

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"Sources are origins that emit particles into the simulation, and all particles must enter the simulation via a source. Sources can be points or have spatial geometry which you can choose to see or hide in simulation space. You can define as many sources as you like for a system, but each source is restricted to emit only one particle type. (If you want to have more than one particle type originate from the same position, you can superimpose sources at the point. ...

... In the source window you assign a particle type to the source and then define the rate and speed of the particles along with their spread angle into the simulation. ..."

The "spread angle" is Applicant's "cone".;

- source window (pg. 8-3);
- source rate (pg. 8-4);
- Spread (pg. 8-5);
- speed (pg. 8-6);
- source position (pg. 8-10);
- display (pg. 8-11);
- geometry (pg. 8-13);
- particle emission and geometry (pp. 8-15 to 8-16);

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- particle generation (pp. 8-16 to 8-17);
- Chapter 9 “Obstacles”;
- Chapter 13, “electric fields”;
- Chapter 15, “particle events”;
- elastic and inelastic particle collisions (pp. 15-1 to 15-2)”.

Kinema/Sim discloses particle sources. Representative’s response is simply not credible. Examiner can only request that Representative please review the art rejection and the art.

Regarding the 103 rejections (page 15, paper 16):

76. In response to applicant's arguments against the references individually (namely, the Ohira and Yamada references, which were the base references in a 103 rejection), one cannot show nonobviousness by attacking references individually where the rejections are based on combinations of references. See *In re Keller*, 642 F.2d 413, 208 USPQ 871 (CCPA 1981); *In re Merck & Co.*, 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986).

Regarding the 103 rejections (page 16, paper 16):

See preceeding comments.

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Conclusion

77. The prior art made previously of record and not relied upon is considered pertinent to applicant's disclosure. Representative still has not provided any comments regarding the cited art.

- **Bouvier et al.**: *"From crowd simulation to airbag deployment: particle systems, a new paradigm of simulation."* This publication discloses details concerning the *Kinema/Sim* software package. The reference apparently does not qualify as prior art since the date of publication is 1/97. However, the reference compactly summarizes the matter disclosed in the Kinema/Sim manual and is provided for Applicant's benefit. See particularly: Section 1, including: section 1.1 (*Introduction and Objectives*), section 1.2 (*Particle Systems*), sections 1.2.1 and 1.2.2; Section 2 (*Particle Systems*), especially section 2.2, wherein:

"A particle system is defined by:

The description of the **particle types**,

The **particle sources which generate the sources**,

The **3D geometry, including obstacles**,

The **evolution of these particles within the system**";

section 2.2.2 wherein the particle object is defined, including, among others:

"its **values for interactions with surfaces** (stick, bounce, penetrate, transform, etc),

its **visualization parameters: color, size, transparency, trail memory, geometry**";

section 2.2.2 (***Generation of Particles***), wherein;

"Generating particles implies the description of an initial state for the system, by defining particles of different types, with imposed positions and velocities. During the simulation, the interaction of these particles with the system will change these initial values, but the **user will have the possibility to create new particles**, with defined position and velocities.

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The particles are generated by sources. Sources are geometric entities emitting only one type of particle. They are defined by:

Their position in the space and their dimension,

Their size and geometry,

Their rate of emission as a function of time,

Their direction of emission: a given vector, a local normal to a surface, or a given trajectory”;

section 2.2.3 (*Evolution of particles*); section 2.2.5 (*Advantages of the Kinema approach to particle systems*), wherein, among other things:

“the system can:

handle collisions of particles with objects, surfaces and with other particles,

manage the position of sources and emission parameters (rate, direction, speed)”;

section 3.6 (*visualization*); and section 5 (*Further simulations under development*), wherein,

“Obstacles and source management facilities enable us to model different kinds of phantoms (scattering environment shapes and radioactive spatial distributions). ...”

- Ohta (U. S. Patent 5,751,607, Method (Sputter Deposition Simulation by Inverse Trajectory Calculation, 1998) discloses the use of Monte Carlo techniques as it pertains to the simulation of sputtering. [of record]

- Jones et al., "Monte Carlo Investigation of Electron-Impact Ionization in Liquid Xenon," Phys. Rev. B., 48, 9382-9387, 1993 teaches the use of Monte Carlo techniques as it pertains to electron transport in condensed media; references are provided to more details descriptions of Monte Carlo techniques. [of record]

- Takagi, "Development of New Materials by Ionized-Cluster Beam Technique," Mat. Res. Soc. Symp. Proc., 27, 501-511, 1984 discloses ion beam clusters ("combined particles") and its relation to deposition. [of record]

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- Cornell Theory Center (1996) discloses an animated simulation of the dynamic failure of 3D solids under tension at the atomistic level using classical molecular dynamics and system sizes from 10 to more than 100 million atoms. [of record]

- XSIMBAD (1996) discloses a Monte Carlo simulation software package. A condition setting user template is shown on pp 3-4; animated simulation results are shown on pp. 5 and 11-12, graphical results are shown on pg. 6 and 11. [of record]

78. These references are a few examples of many references which the examiner has obtained concerning animation as applied to simulation in general, and sputtering, in particular."

79. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

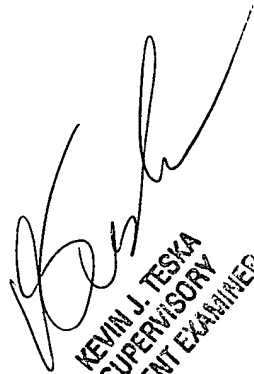
80. A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

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81. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dr. Hugh Jones whose telephone number is (703) 305-0023.

Dr. Hugh Jones

June 4, 2000



KEVIN J. TESKA
SUPERVISORY
PATENT EXAMINER